Atty. Docket No. 30205/39714 Inventors: Geun Su Lee et al.

Title: "Cleaning Solution for Photoresist and Method for

Forming Pattern Using the Same"

Sheet 1 of 3

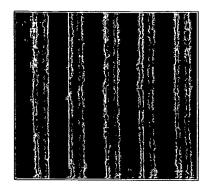


Fig.1

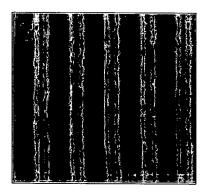


Fig.2

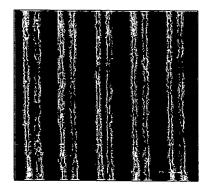


Fig.3

Atty. Docket No. 30205/39714

Inventors: Geun Su Lee et al.
Title: "Cleaning Solution for Photoresist and Method for

Forming Pattern Using the Same"

Sheet 2 of 3

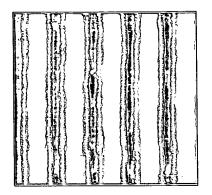


Fig.4

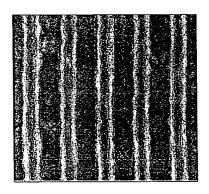


Fig.5

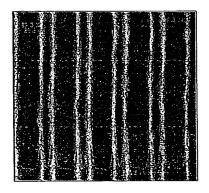


Fig.6

Atty. Docket No. 30205/39714 Inventors: Geun Su Lee et al.

Title: "Cleaning Solution for Photoresist and Method for

Forming Pattern Using the Same"

Sheet 3 of 3

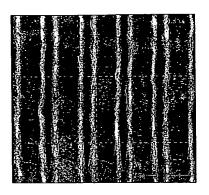


Fig.7

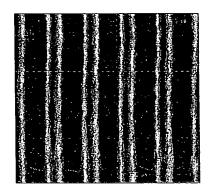


Fig.8

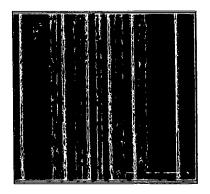


Fig.9